DATASHEET A087 - RÉGULATION DE DÉBIT DANS LA PRODUCTION DE PANNEAUX SOLAIRES PV

APPLICATION NOTE A087-EN04

Flow control in photovoltaic (PV) solar cell production

The manufacturing process for photovoltaic (PV) solar cells - cells that convert sunlight into electricity - consists of many steps like cleaning and etching of silicon wafers, or deposition of layers using physical or chemical vapour deposition techniques (PVD/CVD).

Machines for the production of photovoltaic solar cells consist of a sequence of process chambers where the manufacturing steps take place under controlled conditions, with lock chambers in between. Each of these steps involve the supply of gaseous or liquid chemical compounds. For a company that builds two to three of such machines each week, Bronkhorst was asked to deliver mass flow devices.



Application requirements

Each of the photovoltaic solar cell manufacturing machines consists of up to ten vacuum process chambers in total, utilising several dozens of mass flow controllers to supply gases, liquids and vapours. For this application, it is necessary that the flow devices supply exactly 500 or 1000 sccm - or any desired value - but it is essential that this will occur day after day. So repeatability is as important as accuracy.

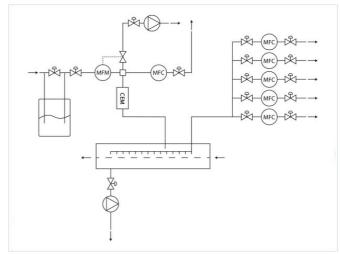
Important topics

- Accurate supply of gases, liquids and vapours
- Repeatability
- Single mass flow controllers for multiple gases

Process solution

Bronkhorst delivered mass flow controllers for the accurate and reproducible supply of gases, vapours and liquids. Usually Bronkhorst <u>EL-FLOW Select</u> thermal mass flow controllers were used here for gas supply. In the case of liquids, most of them were evaporated to vapours by means of a <u>CEM</u> (Controlled Evaporation & Mixing) system in order to react at the surface of substrates in plasma enhanced chemical vapour deposition (PE-CVD) processes. The CEM system consists of a (thermal or Coriolis) liquid flow controller (e.g. <u>LIQUI-FLOW</u> or <u>mini CORI-FLOW</u>), a mass flow controller for carrier gas (e.g. <u>EL-FLOW Select</u>) and a temperature controlled <u>mixing and evaporation device</u>.

The Bronkhorst flow devices are used here for applying layers on crystalline silicon wafers in traditional silicon-based solar cells, as well as for manufacturing thin layers as components of second generation amorphous-silicon-based thin-film solar cells on flexible substrates.



Flow scheme

Let's dive somewhat deeper into the process with an example how to deposit a 'p-n junction' onto a flexible substrate, which is an essential part of the photovoltaic (PV) solar cell to convert sunlight into electrons. Two silicon layers with different dopants have to be applied on top of each other in separate process chambers. In this case, the process medium is silane (SiH₄) and hydrogen (H₂) with a trace gas, which is phosphine (PH₃) for the n-doped layer and diborane (B₂H₆) for the p-doped layer. To clean the vacuum process chambers between the deposition steps using a plasma, gaseous NF₃ is added.

A feature of the <u>EL-FLOW Select</u> thermal mass flow devices is that they can be provided with several (~5) calibration curves for different gases, which has the advantage that a relative low number of these mass flow controllers can be used - each for gases that are somewhat comparable. This efficient use of devices leads to cost reduction.

These devices are also suitable to be applied in adjacent application areas that use vacuum technology, such as the <u>semiconductor industry</u>, and to manufacture light emitting diodes (LEDs) for displays and lighting.

Recommended Products



EL-FLOW SELECT F-201CV

Débit min. 0,16...8 mln/min Débit max. 0,5...25 ln/min Pression 64 bar Conception compacte Grande précision,

excellente répétabilité



CEM EVAPORATOR W-202A

Max. 120 g/h liquide; Max. 10 ln/min gaz Pression 100 bar Débit de vapeur très stable Ratio de gaz/liquide flexible



LIQUI-FLOW™ L13

Débit min. 0,25 ... 5 g/h
Débit max. 5 ... 100 g/h
Pression 100 bar
Conception compacte,
IP40
Communication
analogique, RS232 ou de
fieldbus



MINI CORI-FLOW™ M12

Débit 0...200 g/h Pression 200 bar Indépendant des propriétés du fluide Grande précision



Bronkhorst High-Tech designs and manufactures innovative instruments and subsystems for low-flow measurement and control for use in laboratories, machinery and industry. Driven by a strong sense of sustainability and with many years of experience, we offer an extensive range of (mass) flow meters and controllers for gases and liquids, based on thermal, Coriolis and ultrasonic measuring principles. Our global sales and service network provides local support in more than 40 countries. Discover Bronkhorst®!